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Room temperature NO2 gas sensor based on stain-etched porous silicon: towards a low-cost gas sensor integrated on silicon

H. Mhamdi<sup>1,5</sup>, K. Azaiez<sup>2</sup>, T. Fiorido<sup>3</sup>, R. Benabderrahmane Zaghouani<sup>1\*</sup>, J. L. Lazzari<sup>4</sup>, M. Bendahan<sup>3</sup>, W.

Dimassi<sup>2</sup>

<sup>1</sup>Laboratoire de Photovoltaïque, Centre de Recherches et des Technologies de l'Energie, Technopôle de Borj-

Cédria, BP, 95 Hammam-Lif, Tunis, Tunisie

<sup>2</sup>Laboratoire de Nanomatériaux et Systèmes pour Energies Renouvelables, Centre de Recherches et des

Technologies de l'Energie, Technopôle de Borj-Cédria, BP, 95 Hammam-Lif, Tunis, Tunisie

<sup>3</sup> Aix Marseille Univ, Université de Toulon, CNRS, IM2NP, Marseille, France

<sup>4</sup>Aix Marseille Université, CNRS, CINaM UMR 7325,

Campus de Luminy, Case 913, 163, Avenue de Luminy, 13288 Marseille Cedex 09, France

<sup>5</sup>Faculté des Sciences Mathématiques, Physiques et Naturelles de Tunis

\*Corresponding author: Rabia Benabderrahmane

Tel.:+216 96148416; Fax: +216 79325825

E-mail address: rabia.benabderrahmane@gmail.com

**Abstract** 

In this work, we investigate the use of a new low-cost gas sensor based on porous silicon to detect low

concentration of NO2 at room temperature. In this work, we focused on the gas sensing properties of two

different types of porous silicon (PS) prepared by a simple chemical method namely nano-porous silicon (nano-

PS) and macro-porous silicon (macro-PS). The prepared sensors are characterized by different pores size,

thicknesses and porosity. Electronic properties of the synthesized structures were studied by measuring the

effective minority carrier lifetime using a µPCD lifetime tester. Structural properties and morphology of PS

samples were also presented using Fourier transforms infrared (FTIR) spectroscopy and scanning electron

microscope (SEM). The gas sensing properties of nano-PS and macro-PS were performed at room temperature

for NO2 gas. Macro-PS and nano-PS sensors exhibit different behaviors attributed to the difference in their

morphologies. The tested sensors exhibit considerable sensitivity at room temperature to low concentration of

NO<sub>2</sub> (4 ppm) during response time up to 45 s.

Keywords:

Nano-Porous silicon, Macro-porous silicon, stain-etching, NO<sub>2</sub> detection, room temperature

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#### 1. Introduction

Several materials with large specific surface areas, such as polymer membranes [1], carbon nanotubes [2], and metal oxides [3-5] have been studied as prospective candidates for future gas sensors. Actually, the most used gas sensors are based on metal oxides whose principle is based generally on chemisorption interactions which are oxydo-reduction reactions based on the exchange of electrons between the gas and the sensitive layer. The reactions take place on the surface on specific adsorption sites thermodynamically favorable. These reactions depend on the gas type and adsorption sites. It has been shown that oxygen is necessary to catalyze the sensing reaction in which the gas reacts generally with the adsorbed oxygen molecules. Currently, in the most developed sensors, the sensitive layer is nanostructured, which considerably increases the number of adsorption sites. In this work, one way of improvement consists of increasing the sensor specific surface which can be achieved by using a porous silicon substrate. Porous silicon (PS), an interesting material with large specific surface area, is easily produced by chemical [6, 7] or electrochemical [8] processes. It is indeed a very variable material who's optical, electrical and morphological properties could be modulated by porosity and thickness. It presents a high specific surface up to 1500 m<sup>2</sup>/cm<sup>-3</sup>. Chemical functionalization of the porous silicon surface shows the potential for developing a variety of gas sensors [6]. Recently, PS gas sensor has been investigated especially for NO2 detection [9, 10]. Although PS sensors show good sensitivity when exposed to NO2, some problems such as selectivity, repeatability, response–recovery characteristics and long-term stability need to be considered. In the literature, some research works have reported incomplete recovery, and irreversible behaviors limiting the PS integration in final gas-sensing devices [11, 12]. In addition, the use of multilayer structures with different morphologies based on porous silicon (different pore sizes, porosity) obtained on the same substrate has been investigated for NO<sub>2</sub> gas sensor [13]. In other reports, porous silicon membranes are investigated in gas sensors using hybrid and composite materials leading to the selectivity enhancement [13]. The PS with ordered pore channels may influence considerably the gas-sensing properties, including reversibility and response-recovery time. Moreover, porous silicon sensing properties could be ameliorated by catalyst deposition and modifying PS surface [14].

However, the porous silicon presents unstable Si-H bonds on its surface which are rapidly degraded under ambient conditions leading to surface oxidation and therefore the interface states and dangling bonds presence. The formation of  $SiO_x$  layer is certainly playing an important role on gas detection.

In this work, we present an original study focused on the use of two different types of porous silicon (PS) obtained by a simple and low-cost method as a gas senor at room temperature: nano-porous silicon (nano-PS) and macro-porous silicon (macro-PS). The PS gas sensing properties and response/recovery characteristics at room temperature are investigated and discussed.

#### 2. Experimental details

#### 2.1 Samples preparation:

Nano porous (nano-PS) and macro porous (macro-PS) silicon samples were synthesized via stain etching technique during 2 min using etching solution (HF, HNO<sub>3</sub>, H<sub>2</sub>O) = (1, 2, 3) in volumetric ratio (Fig.1(a)). P-type and N-type silicon substrates with a resistivity of ~1-3  $\Omega$ .cm and a thickness of 200  $\mu$ m were used to elaborate nano-PS and macro-PS samples respectively. To elaborate macro-PS samples, light is used during the etching process in order to create holes necessary for the etching process.

Before PS elaboration, the substrates have followed different cleaning steps to eliminate organic greases by immerging samples in boiling acetone during 10 min then in ethanol during 5 min and deionized water. Finally, the native oxide was etched in 10 % acid hydrofluoric during 1 min, rinsed in deionized water and dried with nitrogen. After porous silicon formation, aluminum (Al) electrodes are deposited on PS surface by thermal evaporation with a thickness of about 100 nm in a parallel configuration.

#### 2.2 Physicochemical samples characterization:

The formed porous silicon was studied using a Fourier Transform Infrared (FTIR) Nicolet MAGNA-IR 560 Spectrometer. The PS morphology was investigated by a scanning electron microscope (SEM). The elemental analysis of PS surface was performed by the X-ray Dispersive Energy (EDX) coupled with SEM. Effective minority carrier lifetime ( $\tau_{eff}$ ) was studied using a microwave induced photoconductive decay technique ( $\mu$ W-PCD). The measurements are performed by Semilab WT-2000 system using a 904 nm laser excitation source.

#### 2.3 Gas sensing measurement:

The gas-sensing performances of the PS sensors were tested in a dynamic gas sensing testing system, as shown in Fig.1 (b). The sensor was placed on a heating plate connected to a temperature controller to adjust the operating temperature. By measuring the resistance change over time between two electrodes under gas, the sensor dynamic response curves were collected. In this work, the gas sensor response is defined as:

$$R_a/R_g$$
 (When sensor is exposed to an oxidizing gas) (Eq. 1-a)  
Or  $R_g/R_a$  (When sensor is exposed to a reducing gas) (Eq. 1-b)

Where  $R_a$  and  $R_g$  are the sensor resistances measured in dry air and under tested gas, respectively. The PS sensors are tested toward exposed gas at room temperature (RT) (25  $\pm$  2 °C). The response and recovery times are also calculated. The response time is measured as the time necessary for the resistance to reach 90 % of the equilibrium value after gas exposure. The recovery time is obtained as the time required reaching 10 % above initial resistance after gas removal. The samples were exposed to different gas as NO<sub>2</sub>, NH<sub>3</sub>, O<sub>3</sub> and CO. Ozone is generated from dry air, using a system based on a UV lamp. The dry air passes through a quartz tube illuminated by the UV lamp. Exposure of oxygen molecules to UV rays leads to the generation of ozone molecules.

#### 3. Results and discussion:

#### 3.1. Porous silicon characterization:

For silicon nanostructuring, there are two possible approaches: the top-down and the bottom-up approaches. In this work, porous silicon is obtained by the top-Down approach consisting in miniaturizing the silicon substrate until obtaining nanometric structures by etching the initial substrate in an acidic solution. The stain-etching process is composed of two chemical reactions occurring simultaneously: the silicon surface oxidation by the nitric acid and the silicon oxide etching by hydrofluoric acid. Porous silicon is characterized by the morphology, the porosity and the thickness. Porosity is defined as the fraction of voids within the porous structure [16]. The quantification of the material loss in the etching process is used as a gravimetric measurement to evaluate the PS porosity and thickness [17]. The following equations are used to obtain the average porosity (P) (Eq. 2).

$$P = \frac{m_1 - m_2}{m_1 - m_3}$$
 (Eq. 2)

The sample was weighted before porosification (m<sub>1</sub>), after porosification (m<sub>2</sub>), and after porous silicon dissolution in 1 wt.% NaOH solution (m<sub>3</sub>).  $\rho$  is the density of silicon and S is the etched area. The porosity of the elaborated porous silicon is about 38% and 66 % for nano-PS and macro-PS respectively. Fig. 2 shows the nano-PS surface morphology obtained by SEM microscopy. The top surface SEM images (Fig. 2(a-b)) shows the presence of pores with nanometric sizes less than 10 nm confirming the synthesis of nano porous structure. The PS layer thickness estimated thanks to the cross-section SEM image (Fig. 2(c)) is about 0.64 µm. Fig. 3(a-b) shows the macro-PS surface morphology. We distinguish the presence of pores with sizes more than 50 nm proving the formation of macro-porous silicon layer with a thickness of 1.6 μm (Fig. 3(c)). The X-ray Dispersive Energy (EDX) coupled to the SEM performed on the nano-PS porous silicon sample shows that no metallic impurities related to the synthesis method were detected (Fig. 2(d)). The presence of an oxygen peak indicates the surface oxidation. In fact, the hydrogenation via HF and the formation of Si-H bonds is only stable during low durations. Stored in ambient atmosphere, the Si-H bonds are rapidly degraded leading to the porous surface oxidation and therefore the presence of dangling bonds which could play an important role in gas sensing mechanism. In order to confirm this observation, FTIR spectra of freshly prepared and oxidized PS samples were performed (Fig.4) showing the vibration bands attributed to SiH<sub>x</sub> and Si-O-Si stretching mode at 2112 cm<sup>-1</sup> and 1092 cm<sup>-1</sup> respectively, the SiH<sub>2</sub> scissors mode (907 cm<sup>-1</sup>), the Si-Si stretching mode (628 cm<sup>-1</sup>), SiH<sub>n</sub> and O-SiH<sub>x</sub> wagging mode at 672.7 cm<sup>-1</sup> 861 cm<sup>-1</sup> respectively[18]. Comparing the two spectra, we notice the reduction of the SiH<sub>x</sub> peak at 2112 cm<sup>-1</sup> against the increase in Si-O peak intensity confirming the PS surface oxidation. Fig. 5 presents the 2D mapping image and the corresponding histogram with 250 µm resolution showing the minority carrier lifetime in p-silicon substrate (Fig. 5(a)), nano-PS sample (Fig. 5(b)), n-silicon substrate (Fig. 5(c)) and macro-PS sample (Fig. 5(d)). As we can notice, the lifetime in freshly prepared nano-PS layer is homogeneous and greater than that in silicon thanks to the surface hydrogenation during the etching process in HF/HNO<sub>3</sub> solution. For the macro-PS sample, a slight enhancement in  $\tau_{eff}$  is also obtained. We note also that the average  $\tau_{eff}$  measured in the macro-PS (13µs) is greater than that of the nano-PS sample (1.9 µs) attributed to the quality of the initial silicon substrate used.

### 3.2 Gas sensing properties:

The gas sensing properties of the nano-PS and macro-PS sensors towards 4 ppm of  $NO_2$  gas were studied at room temperature in dry air. Fig. 6(a) shows the variation of the electrical resistance as a function of time with a temperature increasing from 25 to 50 °C. The results show that the resistance decreases with increasing the temperature proving the semiconductor behavior of the PS sensor. The nano-PS gas sensor response as a function of time at room temperature is shown in Fig.6 (b). This sensor has a response about 1.5 at ambient temperature, as well as reasonable response (45 s) and recovery times (67 s). The gas sensor based on nano-PS is therefore operational in ambient temperature. The recovery time is considered interesting thanks to the low thickness of the PS layer (about 640 nm).

Fig. 6 (c) shows the good repeatability of the nano-PS sensor for three dynamic response cycles for an exposure time of 1 min and for two dynamic cycles for an exposure time of 3 min. For each test, complete recovery of initial resistance is observed. This indicates that porous silicon has a chemical stability when it comes to NO<sub>2</sub>, the gas particles are able to be adsorbed, and then desorbed rapidly at room temperature once the experiment is over. The gas selectivity of porous silicon sensors is also studied. Fig. 6(d) shows the sensor response under

different gas (4 ppm NO<sub>2</sub>, 4 ppm NH<sub>3</sub>, 200 ppb O<sub>3</sub> and 4 ppm CO) at room temperature. As noted, the best response is recorded to NO<sub>2</sub> however the sensor response towards NH<sub>3</sub> and O<sub>3</sub> is very low. When exposed to CO, the sensor does not display any sensitivity. The CO gas is still presenting problems of detection as few research works have reported on CO sensing in particular at room temperature. These results show that NO<sub>2</sub> is the most compatible gas for this sensor. Table 2 recapitulates the different characteristics of the nano-PS sensor. For the different detected gas, the nano-PS sensor exhibits a rapid response proving its efficiency while the highest recovery time is obtained when it is exposed to NH<sub>3</sub>.

The gas sensing properties of the macro-PS sensors towards 4 ppm of NO<sub>2</sub> gas were studied at room temperature. Fig. 7 shows the macro-PS gas sensor response as a function of time. The sensor had a response of 2.35 at room temperature, much higher than nano-PS sensor response. The response and recovery times of this sensor were determinated and the values were about 64 s and 45 min, respectively. This sensor shows a very slow recovery characteristic attributed to the high thickness of the PS layer (about 1.6 μm). The selectivity of macro-porous silicon sensors is also studied. Fig. 7(b) shows the sensor response under different gas (4 ppm NO<sub>2</sub>, 4 ppm NH<sub>3</sub>, 200 ppb O<sub>3</sub> and 4 ppm CO) at room temperature. The macro-PS sensor exhibited the important gas sensing characteristic for NO<sub>2</sub> gas. Table 3 recapitulates the different characteristics of the macro-PS sensor. We can consider that NO<sub>2</sub> gas is the most compatible gas for this sensor.

Compared to the nano-PS sensor results, the increase in sensitivity for the macro-PS sensor is attributed to the obtained morphology (Fig.2 and Fig.3). The nano-PS presents nano-sized pores less than 10 nm however the macro-PS has macro-pores. Besides, the macro-PS sample has a higher porosity justifying that a higher quantity of gas molecules is adsorbed in the macro-PS than in the nano-PS sensor. Comparing the recovery times measured for the two sensors, we note that the gas desorption takes much more time with macro-PS sensor attributed to the porous layer thickness  $(1.6 \, \mu m)$  for macro-PS against  $0.64 \, \mu m$  for the nano-PS).

#### 3.3 Sensing mechanism:

The response of most gas sensors is due to the changes in carrier concentration, usually induced by adsorption-desorption reactions on the sensing materials surface. In recent years, many researchers have investigated the  $NO_2$ -sensing mechanism of porous silicon [20, 21]. It is found that the PS belongs to the surface-controlled type as both surface states and oxygen adsorption play important roles in the  $NO_2$  detection [22].  $NO_2$  acts as an oxidizing gas, which will capture the electrons from the sensing material. In the first step, the atmospheric oxygen molecules, adsorbed onto the PS surface in the form of  $O^-$  and  $O_2^-$  depending on the operational temperature, are extracting electrons from the PS conduction band ((Eq. 7)-(Eq. 9)). In the case of the n-type porous silicon sensor, it leads to the formation of electron-depleted space-charge layer under the PS surface [23], and then the resistance increase.

$$O_2(gas) \rightarrow O_2(ads)$$
 (Eq. 7)

$$O_2(ads) + \acute{e} \rightarrow O_2^-(ads)$$
, T<100 °C (Eq. 8)

$$O_2^-(ads) + \acute{e} \rightarrow 2O^-(ads)$$
, 100 °C

In the second step, when the PS sensor is exposed to NO<sub>2</sub>, the gas molecules may be directly adsorbed onto the PS surface by trapping electrons (Eq. 10), and interact with the chemisorbed oxygen (such as  $O^-$  and  $O_2^-$ ) ((Eq. 11) and (Eq. 12)) [24].

$$NO_2(gas) + \acute{e} \rightarrow NO_2(ads)$$
 (Eq. 10)

$$NO_2(gas) + O_2^{-}(ads) + 2\acute{e} \rightarrow NO_2^{-}(ads) + 2O^{-}(ads)$$
, T<100 °C (Eq. 11)

$$NO_2(gas) + O^{-}(ads) + 2\acute{e} \rightarrow NO_2^{-}(ads) + O^{2-}(ads)$$
, 100 °C

The reaction with  $NO_2$  will increase further the electron depletion layer width and potential barriers, and then increase the sensor resistance [25]. Consequently,  $NO_2$  molecules capture the electrons from PS surface, leading to the decrease of free electron concentration [26] leading to the sensor resistance increase. The PS electrical conductivity is significantly modulated depending upon the presence or the absence of  $NO_2$ , explaining the resistance variations. Fig. 8 presents the  $NO_2$ -sensing mechanism diagram of the n-type porous silicon at room temperature. Initially, the sensing material presents a flat band structure (Fig 8 (a)). At room temperature, the oxygen molecules are chemisorbed in the form of  $O_2$ -, leading to the formation of a depletion layer (Fig. 8(b)). This formed layer would be raised as a result of  $NO_2$  gas molecules interaction with the chemisorbed oxygen (Fig. 8 (c)).

However, when n-type PS is exposed to a reducing gas (electron donor) such as ammonia (NH<sub>3</sub>), the gas molecules adsorbed on the surface are interacting with the chemisorbed oxygen molecules. This reaction leads to the release of electrons trapped in the surface of oxygen and their injection into the porous silicon conduction band [27]. Thereby, the PS resistivity is decreasing. The same explanation could be conducted with p-type porous silicon.

#### 4 Conclusion:

In summary, two types of porous silicon (nano-PS and macro-PS) were prepared for NO<sub>2</sub> detection through simple chemical method. It was found that the prepared PS is promising for low-concentration NO<sub>2</sub> sensing at room temperature. Using the same technique and synthesis parameters, the two prepared sensors exhibit different behaviors. The substrate doping, and accordingly the obtained morphology, should be accounted for the PS gas sensors. In this study, we obtained responses towards low concentration of NO<sub>2</sub> at room temperature so the operational temperature is no longer an issue when using porous silicon as a sensing material. Therefore with porous silicon, the heater is no longer an essential component of the system.

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## **Conflict of Interest Statement:**

The authors declare that they have no conflict of interest.

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## **Figure Caption**

- Figure 1: (a) Schematic illustration of the adopted porous silicon synthesis process. (b) The schematic diagram of the static gas-sensing test system.
- Figure 2: SEM images of nano-PS sample: (a-b) top surface and (c): cross section images (d) EDX diagram of porous silicon.
- Figure 3: SEM images of macro-PS sample: (a-b) top surface and (c): cross section images.
- Figure 4: FTIR absorption spectrum of porous silicon PS sample.
- Figure 5: The 2D mapping image of the minority carrier lifetime in (a) p-silicon, (b) Nano-porous silicon (nano-PS), (c) n-silicon and (d) Macro-porous silicon (macro-PS).
- Figure 6: (a) Resistance variation of nano-PS as a function of time under dry air with simultaneous increase of temperature from 25  $^{\circ}$ C to 50  $^{\circ}$ C (b) Dynamic response and (c) Resistance variation of the nano-PS sensor exposed to 4 ppm of NO<sub>2</sub> (d) Selectivity towards NO<sub>2</sub>, NH<sub>3</sub>, O<sub>3</sub> and CO at room temperature.
- Figure 7: (a) Dynamic response of macro-PS as a function of time under dry air, (b) Selectivity of macro-PS towards NO<sub>2</sub>, NH<sub>3</sub>, O<sub>3</sub> and CO at room temperature.
- Figure 8: The schematic NO<sub>2</sub>-sensing mechanism of n-type porous silicon.

#### **Table**

- Table 1: Comparative of morphological and electronic parameters of nano-PS and macro-PS samples.
- Table 2: The gas sensing properties of the nano-PS sensor towards different gases at room temperature.
- Table 3: The gas sensing properties of the macro-PS sensor towards different gases at room temperature.

Table 1

	Porosity	Thichness of PS layer	Carrier lifetime
Nano-PS	38 %	0.64 μm	1.9 μs
Macro-PS	66%	1.6 µm	13 μs

Table 2

NO <sub>2</sub>	NH₃	O <sub>3</sub>	СО
4 ppm	4 ppm	200 ppb	4 ppm
1.50	1.06	1.10	No response
45 s	70 s	58 s	//
67 s	960 s	240 s	//
	4 ppm 1.50 45 s	4 ppm 4 ppm 1.50 1.06 45 s 70 s	4 ppm 4 ppm 200 ppb  1.50 1.06 1.10  45 s 70 s 58 s

Table 3

Gas	NO <sub>2</sub>	NH₃	O <sub>3</sub>	СО
Gas concentration	4 ppm	4 ppm	200 ppb	4 ppm
Sensibility	2.35	1.10	1.08	No response
Response time	64 s	80 s	60 s	//
Recovery time	45 min	180 min	45 min	//

Figure 1

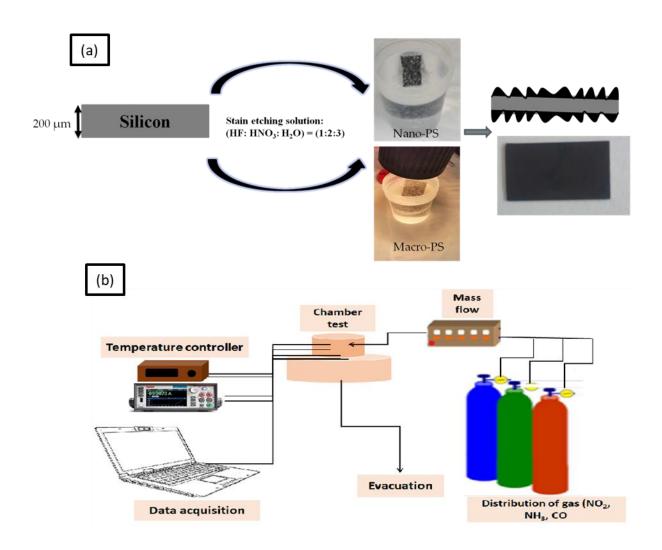


Figure 2

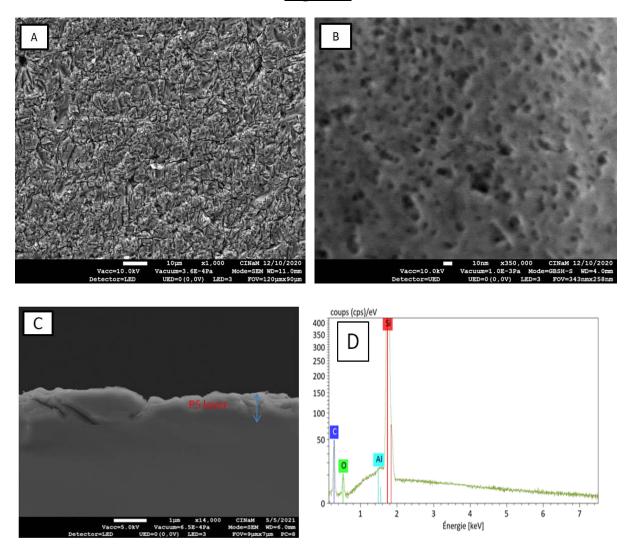
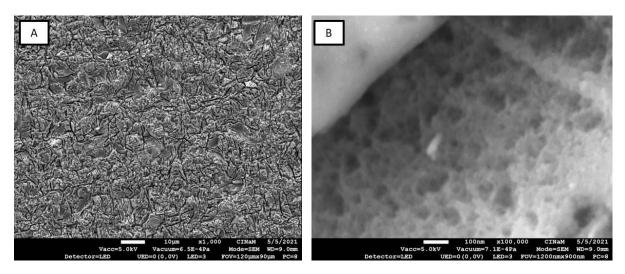


Figure 3



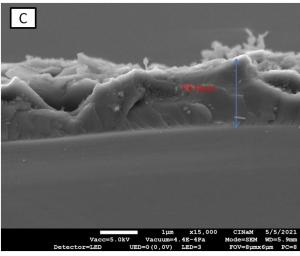
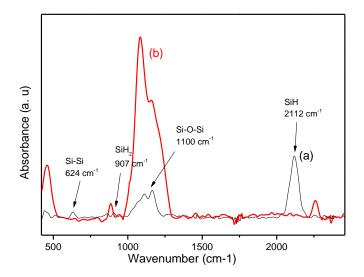
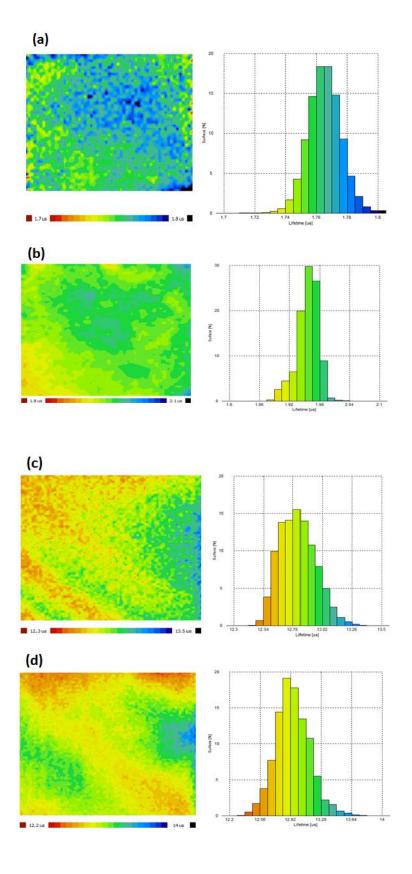


Figure 4



# Figure 5



## Figure 6(a)

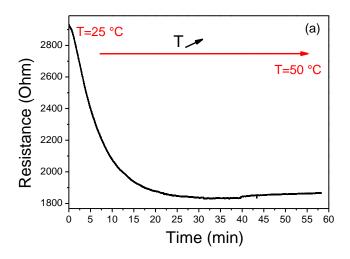


Figure 6(b)

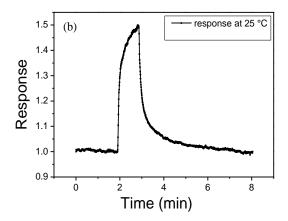


Figure 6(c)

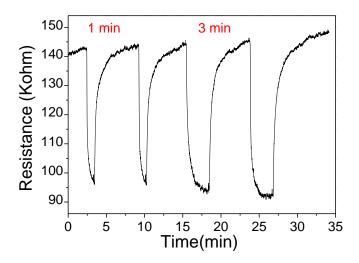


Figure 6 (d)

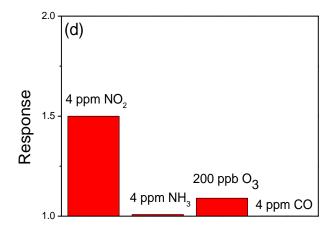


Figure 7(a)

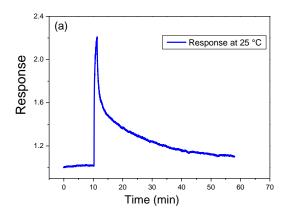


Figure 7(b)

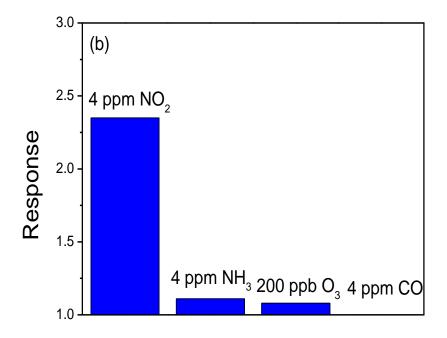


Figure 8

